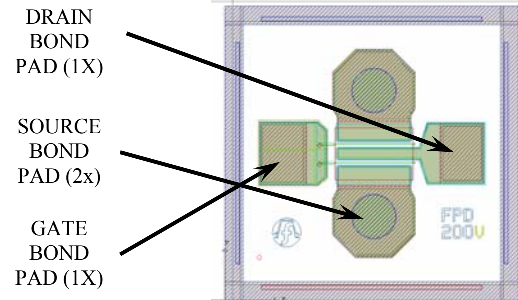
- FEATURES
  - 19 dBm Linear Output Power at 12 GHz
  - 12 dB Power Gain at 12 GHz
  - 17 dB Maximum Stable Gain at 12 GHz
  - 12 dB Maximum Stable Gain at 18 GHz
  - 45% Power-Added Efficiency



DIE SIZE (µm): 400 x 400
DIE THICKNESS: 75 µm
BONDING PADS (µm): >80 x 80

- DESCRIPTION AND APPLICATIONS

The FPD200is an AlGaAs/InGaAs pseudomorphic High Electron Mobility Transistor (PHEMT), featuring a 0.25 µm by 200 µm Schottky barrier gate, defined by high-resolution stepper-based photolithography. The recessed and offset Gate structure minimizes parasitics to optimize performance. The epitaxial structure and processing have been optimized for reliable medium-power applications. The FPD200 also features Si_3N_4 passivation and is available in a low cost plastic package.

Typical applications include commercial and other narrowband and broadband high-performance amplifiers, including SATCOM uplink transmitters, PCS/Cellular low-voltage high-efficiency output amplifiers, and medium-haul digital radio transmitters.

- ELECTRICAL SPECIFICATIONS AT 22°C

Parameter	Symbol	Test Conditions	Min	Typ	Max	Units
RF SPECIFICATIONS MEASURED AT *f* = 12 GHz USING CW SIGNAL						
Power at 1dB Gain Compression	P_{1dB}	V_{DS} = 5 V; I_{DS} = 50% I_{DSS}	18	19		dBm
Power Gain at P_{1dB}	G_{1dB}	V_{DS} = 5 V; I_{DS} = 50% I_{DSS}	10.5	12.0		dB
Power-Added Efficiency	PAE	V_{DS} = 5V; I_{DS} = 50% I_{DSS}; P_{OUT} = P_{1dB}		45		%
Maximum Stable Gain (S_{21}/S_{12})	SSG					
f = 12 GHz		V_{DS} = 5 V; I_{DS} = 50% I_{DSS}	16	17		dB
f = 24 GHz			10.5	12		
Saturated Drain-Source Current	I_{DSS}	V_{DS} = 1.3 V; V_{GS} = 0 V	45	60	75	mA
Maximum Drain-Source Current	I_{MAX}	V_{DS} = 1.3 V; $V_{GS} \cong$ +1 V		120		mA
Transconductance	G_M	V_{DS} = 1.3 V; V_{GS} = 0 V		80		mS
Gate-Source Leakage Current	I_{GSO}	V_{GS} = -5 V		1	10	µA
Pinch-Off Voltage	$\|V_P\|$	V_{DS} = 1.3 V; I_{DS} = 0.2 mA	0.7	1.0	1.3	V
Gate-Source Breakdown Voltage	$\|V_{BDGS}\|$	I_{GS} = 0.2 mA	12.0	14.0		V
Gate-Drain Breakdown Voltage	$\|V_{BDGD}\|$	I_{GD} = 0.2 mA	14.5	16.0		V
Thermal Resistivity (see Notes)	θ_{JC}	V_{DS} > 3V		280		°C/W

ABSOLUTE MAXIMUM RATINGS[1]

Parameter	Symbol	Test Conditions	Min	Max	Units
Drain-Source Voltage	V_{DS}	$-3V < V_{GS} < +0V$		8	V
Gate-Source Voltage	V_{GS}	$0V < V_{DS} < +8V$		-3	V
Drain-Source Current	I_{DS}	For $V_{DS} > 2V$		I_{DSS}	mA
Gate Current	I_G	Forward or reverse current		10	mA
RF Input Power[2]	P_{IN}	Under any acceptable bias state		100	mW
Channel Operating Temperature	T_{CH}	Under any acceptable bias state		175	ºC
Storage Temperature	T_{STG}	Non-Operating Storage	-40	150	ºC
Total Power Dissipation	P_{TOT}	See De-Rating Note below		0.5	W
Gain Compression	Comp.	Under any bias conditions		5	dB
Simultaneous Combination of Limits[3]		2 or more Max. Limits		80	%

[1]$T_{Ambient}$ = 22°C unless otherwise noted [2]Max. RF Input Limit must be further limited if input VSWR > 2.5:1

[3]Users should avoid exceeding 80% of 2 or more Limits simultaneously

Notes:

- Operating conditions that exceed the Absolute Maximum Ratings could result in permanent damage to the device.
- Thermal Resitivity specification assumes a Au/Sn eutectic die attach onto a Au-plated copper heatsink or rib.
- Power Dissipation defined as: $P_{TOT} \equiv (P_{DC} + P_{IN}) - P_{OUT}$, where
  P_{DC}: DC Bias Power
  P_{IN}: RF Input Power
  P_{OUT}: RF Output Power
- Absolute Maximum Power Dissipation to be de-rated as follows above 22°C:
  P_{TOT}= 500mW – (3.6mW/°C) x T_{HS}
  where T_{HS} = heatsink or ambient temperature.

Example: For a 85°C heatsink temperature: P_{TOT} = 0.5W – (0.0036 x (85 – 22)) = 0.27W

HANDLING PRECAUTIONS

To avoid damage to the devices care should be exercised during handling. Proper Electrostatic Discharge (ESD) precautions should be observed at all stages of storage, handling, assembly, and testing. These devices should be treated as Class 1A per ESD-STM5.1-1998, Human Body Model. Further information on ESD control measures can be found in MIL-STD-1686 and MIL-HDBK-263.

ASSEMBLY INSTRUCTIONS

The recommended die attach is gold/tin eutectic solder under a nitrogen atmosphere. Stage temperature should be 280-290°C; maximum time at temperature is one minute. The recommended wire bond method is thermo-compression wedge bonding with 0.7 or 1.0 mil (0.018 or 0.025 mm) gold wire. Stage temperature should be 250-260°C.

APPLICATIONS NOTES & DESIGN DATA

Applications Notes are available from your local Filtronic Sales Representative or directly from the factory. Complete design data, including S-parameters, noise data, and large-signal models are available on the Filtronic web site.